

INFORMATION DISCLOSURE CITATION

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Applicant Hideaki MASUDA et al.	
Filing Date January 15, 2004	Group:

U.S. PATENT DOCUMENTS						
Examiner Initial*	Document Number	Issue Date	Name	Class	Sub Class	Filing Date If Appropriate
T-D	6,287,973 B2	09/11/2001	Aoi	—	—	

FOREIGN PATENT DOCUMENTS						
Document Number	Publication Date	Country	Class	Sub Class	Translation Yes or No	

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)	
T-D	Hasegawa et al.; "COPPER DUAL DAMASCENE INTERCONNECTS WITH LOW-K ($K_{EFF} < 3.0$) DIELECTRICS USING FLARE™ AND AN ORGANO-SILICATE HARD MASK"; International Electron Devices Meeting (IEDM), pages 623-626, (1999)

Examiner T. DANG	Date Considered 1/28/05
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